Attorney's Docket No. 018414-060

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

)

n re Patent Application of

Jang F. CHEN

Group Art Unit: 1503

Application No.: 08/149,122

Examiner: T. Mosley

Filed: November 3, 1993

For: METHOD FOR IMPROVED

LITHOGRAPHIC PATTERNING IN A SEMICONDUCTOR FABRICATION

PROCESS

PETITION UNDER 37 C.F.R. §1.312(b)

Honorable Commissioner of Patents and Trademarks Washington, D.C. 20231

Sir:

Applicant hereby petitions for entry of the accompanying Amendment Pursuant To 37 C.F.R. §1.312(b).

This Amendment is directed solely to the correction of typographical errors in the claims, and does not affect their scope as allowed. These errors were only discovered after the Issue Fee was paid, when the file was being reviewed in connection with the preparation of a response in the corresponding PCT application.

Entry of the Amendment is submitted to be proper, and is therefore requested. Accompanying this Petition is a check for the required fee under 37 C.F.R. §1.17(i).

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS

1,122

By:

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Date: May 16, 1994